APR 0 2 2003

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PLICATION OF: Kenichi HIROTA, et al. IN RE

L NO: 09/700,704 🗠

GAU:

1746

FILED:

November 24, 2000

EXAMINER: Kornakov, Michail

FOR:

CLEANING SOLUTION AND CLEANING METHOD FOR COMPONENT OF SEMICONDUCTOR

PROCESSING APPARATUS

REQUEST FOR EXTENSION OF TIME **UNDER 37 C.F.R. 1.136**

ASSISTANT COMMISSIONER FOR PATENTS WASHINGTON, D.C. 20231

SIR:

It is hereby requested that a three month extension of time be-granted to April 2, 2003 for

filing a response to the Official Action dated: October 2, 2002

responding to the requirements in the Notice of Allowability dated:

filing the Formal Drawings. The Issue Fee due

has been timely filed.

responding to the Notice to File Missing Parts of Application dated:

filing a Notice of Appeal. A timely response to the final rejection, due

has been filed.

filing an Appeal Brief. A Notice of Appeal was filed on:

Applicant claims small entity status. See 37 CFR 1.27. Therefore, the fee amount shown below is reduced by one-half.

The required fee of \$930.00 is enclosed herewith by check and any further charges may be made against the Attorney of Record's Deposit Account No. 15-0030. A duplicate copy of this sheet is enclosed.

Respectfully Submitted,

OBLON, SPIVAK, McCLELLAND, MAIER & NEUSTADT, P.C.

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